

Application No. 09/633,002
Amendment dated November 13, 2003
Reply to Office Action dated June 17, 2003

12/15/03

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Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

Claims 1-10 (canceled).

Claim 11 (currently amended): A method for removing a deposited film inside a chamber which comprises:

providing a hot element in the chamber, said hot element disposed away from the deposited film, the hot element having at least a surface which comprises platinum;
exhausting said chamber;
heating the hot element to 400°C. or higher;
supplying into the chamber a cleaning gas containing at least one halogen of a fluorine atom and a chlorine atom;
contacting the cleaning gas with the heated hot element to decompose and/or activate the cleaning gas and generate an activated species therefrom;
allowing the activated species to convert the deposited film into a gaseous substance; and
removing the gaseous substance from the chamber.

Claim 12 (previously presented): The method according to claim 11, wherein said chamber comprises a CVD apparatus and the method further comprises:

heating the hot element;
supplying a material gas to the chamber;
contacting the material gas with the hot element to cause decomposition and/or activation of the material gas by said hot element; and
forming the deposited film which comprises at least one element from said material gas on a substrate.